

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	255	nitride adj (based containing) with (mask masking)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/12/20 15:04
L2	26	1 and (mask masking) near4 (groove recess concave\$4 curv\$4)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/12/20 15:11
L3	1	10/881180	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/12/20 15:12
L4	1	10/081180	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/12/20 15:17
L5	0	(nitride adj based with recess adj portion with mask with void with element adj region).clm.	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/12/20 15:19